Spectral crosstalk suppressing design of simultaneous two-color HgCdTe infrared focal plane arrays

Zhen-Hua Ye, Peng Zhang, Chun Lin, Xiao-Ning Hu, Rui-Jun Ding, Li He

Key Laboratory of Infrared Imaging Materials and Detectors, Shanghai Institute of Technical Physics,

Chinese Academy of Sciences, Shanghai 200083, China

e-mail: zhye@mail.sitp.ac.cn

Abstract Spectral crosstalk suppressing design of simultaneous two-color HgCdTe medium-wave/long-wave (MW/LW) infrared n-p-p-n detector is carried out, using commercial Technology Computer Aided Design (TCAD) software *Apsys*. A compositional barrier between two absorption layers is introduced and designed to suppress spectral crosstalk. MW-to-LW crosstalk can be notably suppressed to 2.1% while LW-to-MW crosstalk can be maintained less than 1%.

Keywords two-color detector; HgCdTe; barrier layer; spectral crosstalk

I. INTRODUCTION

HgCdTe is the most widely used material for infrared detection, due to its advantages including continuously tunable bandgap, high electron mobility and the potential to operate at high temperatures[1,2]. Two-color HgCdTe infrared focal plane arrays (IRFPAs) can detect two distinct spectral bands and discriminate both absolute temperature and unique signatures of objects in the scene [3]. Two-color detectors can eliminate the spatial alignment and temporal registration problems that exist whenever two single-color IRFPAs are used, to simplify optical design, and reduce size, weight, and power consumption [4,5]. Spectral crosstalk existing between two bands can influence the function of discrimination. It will be effectively suppressed by incorporating a compositional barrier between two absorption layers [6]. In this paper, the barrier composition and thickness is optimized according to practical technical parameters.

II. MODEL AND METHOD

The investigated simultaneous two-color MWIR/LWIR Hg_{1-x}Cd_xTe detector adopts a four-layer n-p-p-n structure grown by molecular bam epitaxy (MBE) on GaAs substrate. Figure 1 shows a cross-sectional schematic of the detector. The cutoff wavelengths of the two back-to-back photodiodes are approximately 5µm (x = 0.304) and 10µm (x = 0.225), respectively. The donor densities of the 2-µm-thick MW-n layer and LW-n layer are both 1×10^{17} cm⁻³. The acceptor densities of the 6-µm-thick MW-p layer and 8-µm-thick LW-p layer are both 1×10^{15} cm⁻³. The barrier is included between the MW and LW absorption layers with doping concentration of 1×10^{15} cm⁻³ and adjustable thickness and composition. The device is modeled to operate at zero bias, 77K with light illumination at the bottom. Device performance in this work is calculated using finite-element modeling (FEM) simulator *Apsys* from Technology Computer Aided Design (TCAD) Software Crosslight, by simultaneously solving the Poisson equation and carrier continuity equations.

III. SIMULATION RESULTS

The quantum efficiency of devices with a 0.2-µm-thick barrier (x = 0.40) and without barrier are displayed in Fig.2. The barrier can increase the quantum efficiency of the MW diode in the MW-band while decreasing the undesired response of the LW diode in the same waveband. This implies that the barrier can effectively suppress the electron diffusion from the absorption region of the MW photodiode to that of the LW photodiode, and thus reduce crosstalk. MW-to-LW crosstalk is defined as the ratio of the signal produced by MW radiation to that produced by LW radiation among the output signal of LW photodiode. Correspondingly, LW-to-MW crosstalk is defined as the ratio of the signal produced by LW radiation to the signal produced by MW radiation among the output signal of MW photodiode. According to the data in Fig. 2, MW-to-LW crosstalk with barrier is 2.2%, much lower than the counterpart 5.7% while LW-to-MW crosstalk are 0.48% and 0.82%, respectively, both satisfying the actual application. Therefore, introducing a barrier is indispensible.

Figure 3 presents the comparison of the quantum efficiency with the barrier thickness *d* fixed at 0.2 μ m while composition *x* changing from 0.31 to 0.40. The quantum efficiency demonstrates a desired variation with ascending *x* and tends to be stable when *x* exceeds 0.36. Figure 4 displays the comparison of the quantum efficiency with *x* settled at 0.32 while *d* changing from 0.05 μ m to 0.8 μ m. The variation of the quantum efficiency is desirable when the barrier layer gets thicker. Subsequent work demonstrates that larger *x* will weaken the dependence of the quantum efficiency on *d*.

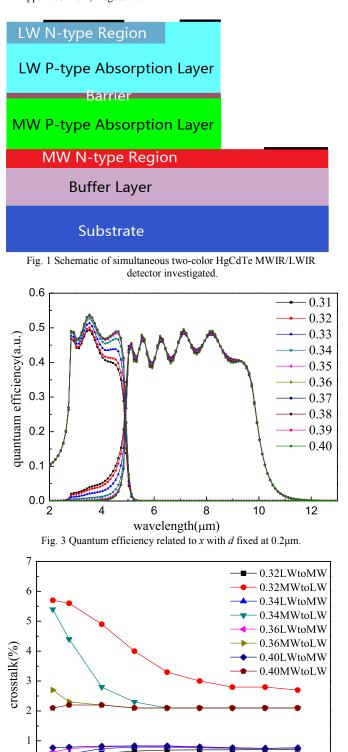
The relation between crosstalk and thickness d at different composition x's is summarized in Fig.5. MW-to-LW crosstalk decreases with increasing d, and LW-to-MW crosstalk has a negligible fluctuation below 0.83%. Consequently, acceptable spectral crosstalk can be obtained by the proper combination of sufficiently large x and d.

IV. CONCLUSION

Simulation results demonstrate that introducing a compositional barrier between two absorption layers can effectively suppress the spectral crosstalk of simultaneous two-color HgCdTe MW/LW n-p-p-n IR detector. With proper combination of sufficiently large barrier composition x and thickness d, MW-to-LW crosstalk can be optimized to be as low as 2.1% while LW-to-MW crosstalk can be controlled no more than 1%.

REFERENCES

- [1] Y. G. Chen, W. D. Hu, X. S. Chen, J. Wang, X. F. Wang, C. H. Yu, W. Lu, "Temperature dependence on photosensitive area extension in HgCdTe photodiodes using laser beam induced current." Opt. Eng., vol. 51, pp. 036401, 2012.
- J. Wang, X. S. Chen, W. D. Hu, L. Wang, W. Lu, F. Q. Xu, J. Zhao, Y. [2] L. Shi, R. B. Ji, "Amorphous HgCdTe infrared photoconductive detector with high detectivity above 200 K," Applied Physics Letters, vol. 99, pp. 113508, 2011.
- K. Joʻzʻwikowski and A. Rogalski, "Computer modeling of dual-band HgCdTe photovoltaic detectors," Journal Of Applied Physics, vol. 90(3), [3] pp. 1286-1291, August 2001



thickness(µm) Fig. 5 Crosstalk as a function of *d* for different *x*'s

0.5

0.7

0.6

0.4

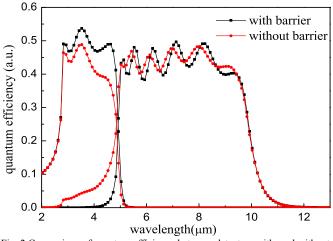
0.3

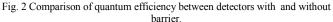
0.2

0.1

0.0

- [4] E. Bellotti and D. D. Orsogna, "Numerical analysis of HgCdTe simultaneous two-color photovoltaic infrared detectors," IEEE Journal of Quantum Electronics, vol. 42, pp. 418-426, 200 6.
- P. R. Norton, Proc.SPIE, vol. 3698, 1999 [5]
- W. D. Hu, X. S. Chen, F. Yin, Z. H. Ye, C. Lin, X. N. Hu, Z. J. Quan, Z. [6] F. Li, W. Lu, "Numerical analysis of two-color HgCdTe infrared photovoltaic heterostructure detector", Opt Quant Electron, vol. 41, pp. 699–704, 2009





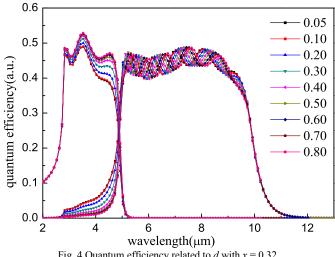


Fig. 4 Quantum efficiency related to d with x = 0.32

0.9

0.8